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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application of: Jyunichi NAKAMURA et al. Confirmation No.: 5720  
Serial No.: 10/649,745 Art Unit: 2826  
Filed: August 28, 2003 Examiner: A. WILLIAMS  
For: **MULTILAYERED SUBSTRATE** Atty Docket No: 060914-117-US  
**FOR SEMICONDUCTOR**  
**DEVICE**

**AMENDMENT AFTER FINAL REJECTION**

Box AF  
U.S. Patent and Trademark Office  
Randolph Building  
104 Dulany Street  
Alexandria, Virginia 22314

Sir:

In response to the outstanding Final Office Action dated May 27, 2005, please amend the above-referenced patent application as follows.

**Amendments to the claims** begin at page 2; and

**Remarks** begin at page of this Amendment.